## Optimization of 3D 1×4 Multimode Interference Splitter Based on Polymer Material Platform

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**Abstract.** This paper presents design, simulation, and optimization of the three-dimensional  $1\times4$  optical multimode interference splitter using IP-Dip polymer as a core and polydimethylsiloxane (PDMS) Sylgard 184 as a cladding. The splitter was simulated by using beam propagation method in BeamPROP simulation engine of RSoft photonic tool and optimized for an operating wavelength of 1.55  $\mu$ m. According to the minimum insertion loss, the dimensions of the MMI coupler and the length of the whole MMI splitter structure were optimized applying a waveguide with a core size of  $4\times4$   $\mu$ m<sup>2</sup>. The objective of the study is to create a design for fabrication by three-dimensional direct laser writing optical lithography.